



CAPILAI N, MORTAR FOR CAPILLARITY MOISTURE SANITATION



Description

Special mortar for the cleaned of the facade or wall affected by rising capillary damp. Before applying the CAPILAI N mortar TEAIS CAPI C must be injected in order to reduce as possible the capillary on the facings. Indoors are cladding with PERLAIS M or PERLAIS E and outdoors with REPOIS M o REPOIS R. White colour.

Aplication

It is used for cleaning walls and facades affected by rising dampness.

Surface preparation

The background of application must be free of grease, oil, dust or paint. Any previous covering, if any, must be removed until the support is compact and stable. Dampen the support before the application of CAPILAI N.

Modes of application

Mix with 25% of water approximately (25 litres of water for every 100 kg of



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product). Leave to stand for 5 to 10 minutes. Then apply in a thickness of 10 to 15 mm and never smoothen with a trowel. Finally leave to dry for 1 to 7 days depending on room temperature.

- In interiors, PERLAIS-E are used. In exteriors, PINSIL D.

If humidities capillarity prior application of a system of injections to cut rising damp, as the Teais Capi C system that allows efficient lock moisture wicking, and then if you will need can end the Capilais mortar.

Clean up

Clean using large amounts of water.

Data sheet

Powder density $1,15 \pm 0,05$ g/cc

Water absorption $20 \pm 3\%$

Mass of density $1,950 \pm 0,05$ g/cc

Adherence > 2 Kg/cm²

Compressive resistance > 30 Kg/cm²

Flexural strength resistance > 10 Kg/cm²

Colour/swhite

Temperature of work 5 to 30°C

Performance

20 kg per sqm in 2 mm thick layer.

Storage

It is recommended to store this product for 2 years in its tightly closed original packages, kept away from humidity.



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